## Influence of Interfacial Water Activity in the Electrocatalysis of CO and Methanol Oxidation: Combination of Electrochemistry and Synchrotron based *In-situ* XAS Data

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The adsorption properties of carbon monoxide on metal surfaces have been investigated in great detail using modern spectroscopic and Ultra High vacuum (UHV) techniques.<sup>1</sup> It has been well established from these studies that the surface structure of adsorbed CO (CO<sub>ads</sub>) and the oxidation of adsorbed CO species on Pt single crystal surfaces is potential dependant above 0.5 V. The kinetics of CO<sub>ads</sub> on Pt depend on many factors including CO<sub>ads</sub> surface coverage and its surface structure, its mobility on the electrode surface and the presence of anions on the electrode surface. Of all these factors that affect the kinetics of CO oxidation, the current state of the art CO tolerant electrocatalysts rely on the 'bifunctional approach' where a second alloying element such as Ru, Sn and Mo can initiate the oxidation of CO due to the presence of surface oxygenated species even at lower potentials.<sup>2-4</sup> A model based on the bifunctionality of an alloying metal such as Ru are however poor for methanol oxidation.5,6

Previously, a 3-fold enhancement in activity for CO oxidation was shown on a PtMo/C relative to a PtRu/C in a PEMFC operating at 85°C under an anodic H<sub>2</sub> stream mixed with 100ppm CO. Two distinct CO stripping peaks were observed both in a PEM half cell and a flooded electrolyte cell.<sup>7, 8</sup> This suggests that the CO stripping occurs on both the Mo and the Pt atoms on the surface, however at different potentials. From kinetic studies of H<sub>2</sub> and CO oxidation on smooth and well defined PtMo surfaces, it was concluded that the oxidation states of the Mo surface atoms determine the electrocatalytic activity on these alloys.<sup>9, 10</sup> In-situ X-ray absorption data (XANES and EXAFS) at the Pt L and Ru and Mo K edges confirm an increase in Pt d-band vacancy concentration and a lower Pt-Pt bond distance on these type of alloys.<sup>8</sup> It was concluded that, while there is a competition between oxide species and CO adsorption for Ru surface sites on a PtRu/C, the Mo surface on a PtMo/C was shown to have no affinity for CO and as a result is available for efficient CO oxidation. However, a more complicated interaction was envisaged for methanol oxidation which results in a build up of C1 oxide species on a PtMo/C in contrast to a PtRu/C. Mechanistic studies on decomposition of methanol on Pt surfaces by Wieckowski et. al.<sup>11</sup> in UHV and electrochemical environments suggests that the cleavage of the C-H bond on Pt surface is a more favorable rate determining step (rds) in an electrochemical environment than the O-H bond breakage due to the hydrophilic interactions between the methanol OH and surrounding water.

Previously, the inherent activity for ORR on supported Pt and Pt alloy nanoparticles without the effect of oxide formation via activation of water was investigated using higher concentrations of trifluoromethane sulfonic acid (TFMSA).<sup>12, 13</sup> The enhancement of ORR activity under low water content was shown to agree well with the lowering of oxide formation.<sup>14</sup> The present investigation focuses on the study of CO and methanol electro-oxidation pathways on supported Pt and Pt based electrocatalysts in different concentrations of TFMSA and to compare and correlate the influence of water activation on the electrocatalysis of CO and CH<sub>3</sub>OH. The kinetics of CO oxidation would also be discussed in detail using rotating disk electrode (RDE) polarization data and stripping voltammetry. The short range atomic order and the electronic properties of the Pt and the alloying metals based on *in-situ* XAS would be discussed under surface adsorbed/poisoned conditions.

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## References

- 1. N. M. Markovic and P. N. Ross, *Surface Science Reports*, **45**(4-6), 117 (2002)
- 2. M. Watanabe and S. Motoo, *J. Electroanal. Chem.*, **60**, 275 (1975)
- T. D. Jarvi and E. M. Stuve, Fundamental aspects of vacuum and electrocatalytic reactions of methanol and formic acid on platinum surfaces, in Electrocatalysis, J. Lipkowski, Editor. 1998, Wiley. p. 400.
- 4. M. Watanabe, M. Shibata and S. Motoo, *J. Electroanal. Chem.*, **187**(2), 161 (1985)
- 5. S. Mukerjee and J. McBreen, *Journal of the Electrochemical Society*, **146**(2), 600 (1999)
- K. Wang, H. A. Gasteiger, N. M. Markovic and P. N. Ross, Jr., *Electrochimica Acta*, **41**(16), 2587 (1996)
- S. Mukerjee, S. J. Lee, E. A. Ticianelli, J. McBreen, B. N. Grgur, N. M. Markovic, P. N. Ross, J. R. Giallombardo and E. S. De Castroc, *Electrochemical and Solid-State Letters*, 2(1), 12 (1999)
- 8. S. Mukerjee and R. C. Urian, *Electrochimica Acta*, **47**(19), 3219 (2002)
- 9. B. N. Grgur, N. M. Markovic and P. N. Ross, Jr., Journal of Physical Chemistry B, **102**(14), 2494 (1998)
- B. N. Grgur, G. Zhuang, N. M. Markovic and P. N. Ross, Jr., *Journal of Physical Chemistry B*, **101**(20), 3910 (1997)
- K. Franaszczuk, E. Herrero, P. Zelenay, A. Wieckowski, J. Wang and R. I. Masel, *J. Phys. Chem.*, **96**(21), 8509 (1992)
- V. Srinivasamurthi, R. C. Urian and S. Mukerjee. in Book of Abstracts, 202nd Meeting of The Electrochemical Society - Salt Lake City, UT, October 20-25, 2002.
- V. Srinivasamurthi, R. C. Urian and S. Mukerjee. in Book of Abstracts, 203rd Meeting of The Electrochemical Society - Paris, France, April 27-May 2, 2003.
- 14. V. S. Murthi, R. C. Urian and S. Mukerjee, J. *Phys. Chem. (in press)*,